

66307-373-7



IFW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: ) PATENT  
Tiancun XIAO )  
Serial No.: 10/588,156 ) GROUP: 1621  
Filed: 25 September 2006 )  
CATALYTIC REACTION BETWEEN ) EXAMINER:  
METHANOL AND A PEROXIDE )  
 ) CUSTOMER NO.: 25269  
 ) CONFIRMATION NO. 9209

\* \* \* \* \*

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

May 7, 2007

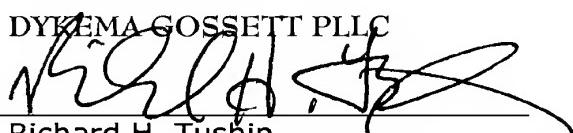
Sir:

The inventor herewith submits copies of documents listed in the International Search Report, dated 18 May 2005, and U.S. Patent No. 6,485,851.

Respectfully submitted,

By:

DYKEMA GOSSETT PLLC

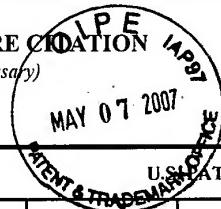
  
Richard H. Tushin  
Registration No. 27,297  
Franklin Square, Third Floor West  
1300 I Street N.W.  
Washington, DC 20005-3353  
(202) 906-8680

DC01\119645.1

ID\RHT ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /W.L./

## INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)



Docket Number (Optional)

66307-373-7

Application Number

10/588,156

Applicant(s)

Tiancun XIAO

Filing Date

9/25/2006

Group Art Unit

1621

## U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		6485851	11/2002	NARAYANAN et al.			
-		3607066	9/1971	BASCH et al.			

## U.S. PATENT APPLICATION PUBLICATIONS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

## FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
		2005015658	2/2005	WIPO				
		2001226102	8/2001	JAPAN				
		2002343403	11/2002	JAPAN				

## OTHER DOCUMENTS

(Including Author, Title, Date, Pertinent Pages, Etc.)

		English Abstract of JP 2001226102
		English Abstract of JP 2002343403

EXAMINER

/Wayne Langel/

DATE CONSIDERED

04/08/2008

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.